

Supporting Information

Poly(vinylidene fluoride) foams: a promising low- k dielectric and heat insulating material

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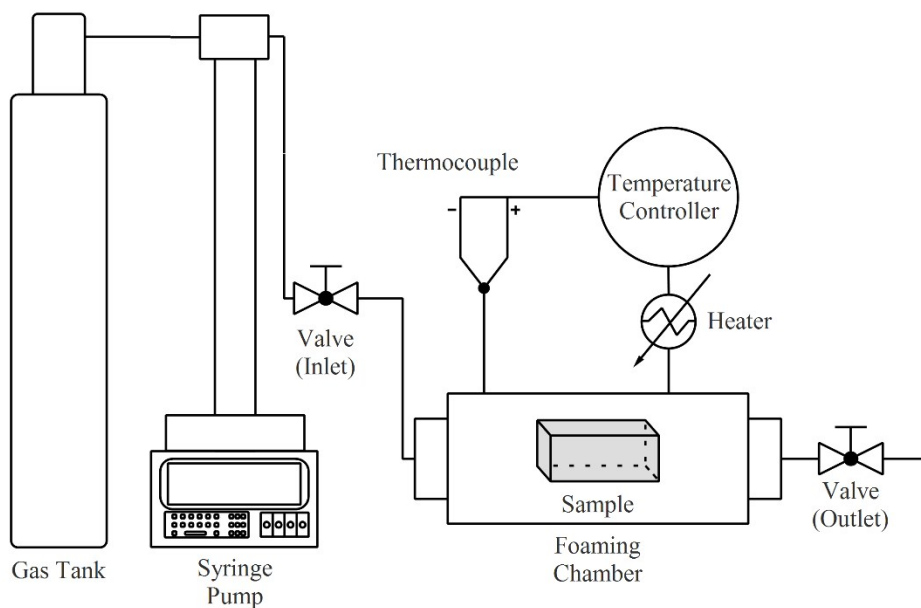


Fig. S1 schematic illustration of home-made batching foaming instrument.

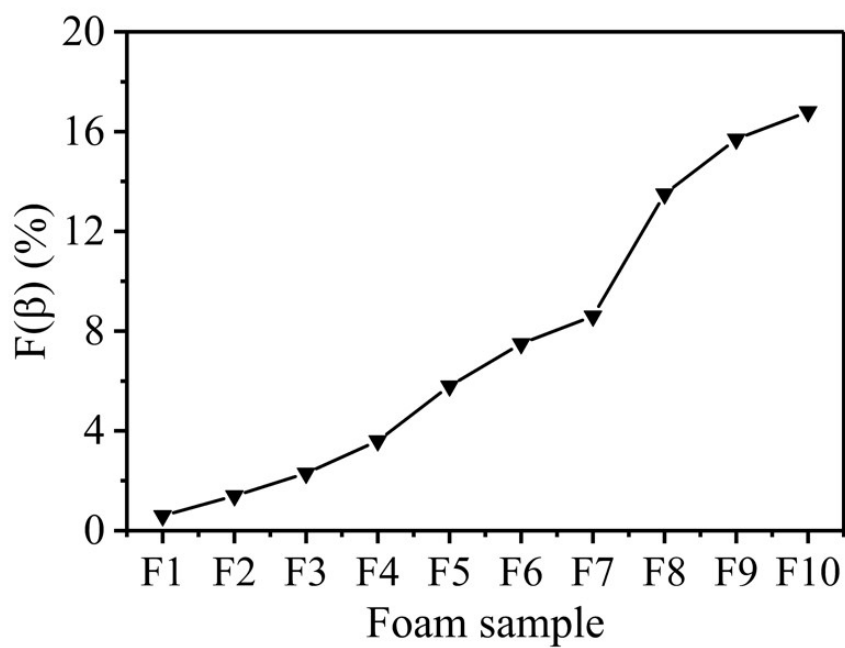


Fig. S2 The relative quantity of β phase ($F(\beta)$) in PVDF foams derived from XRD.

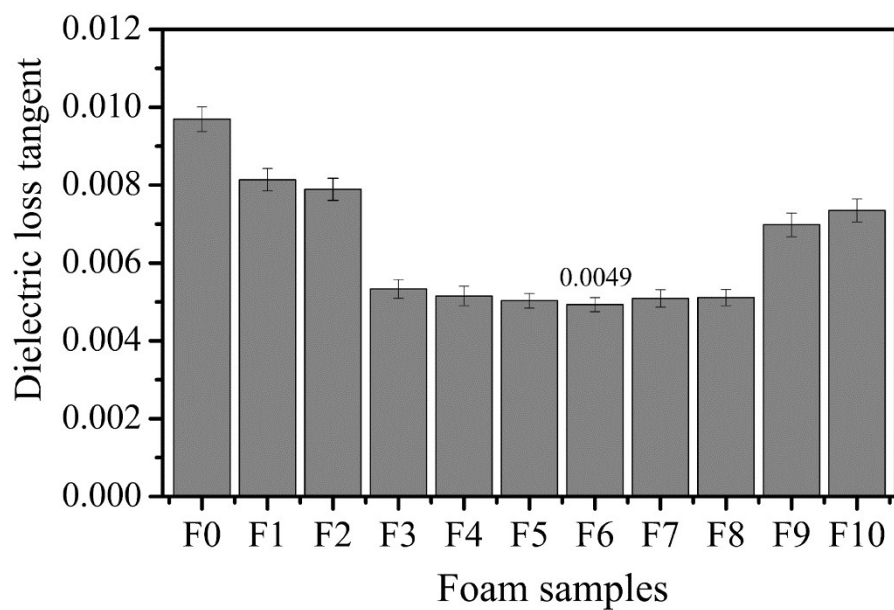


Fig. S3 Dielectric loss tangent of PVDF foams with various void fractions at the frequency of 1,000 Hz.